

PATENT Attorney Docket No.: MUL-003

(5551/10)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT(S):

Yuan

SERIAL NO .: FILING DATE: 10/002.909 November 2, 2001 GROUP NO .: EXAMINER:

Nguyen, Dilinh P.

2814

TITLE:

Shallow-Mesa Structure for Planar PIN and APD Photodiodes

Commissioner for Patents Washington, D.C. 20231

RESPONSE TO RESTRICTION REQUIREMENT

Dear Sir:

This paper responds to the Restriction Requirement, mailed from the U.S. Patent and Trademark Office on January 24, 2003, in connection with the patent application identified above.

The Examiner has required Applicant to elect one of two perceived patentably distinct groups of claims: Group I (claims 1-7) and Group II (claims 8-15). Applicant therefore hereby elects Group I (claims 1-7) for prosecution at this time.

Applicant respectfully requests that the application now proceed promptly to examination. Applicant believes that no fees are necessitated by the present Response. However, in the event that fees are due, the Commissioner is hereby authorized to charge any such fees to Deposit Account No. 20-0531.

Respectfully submitted.

Date: February 21, 2003

Reg. No.: 35,722

Tel. No.: (617) 248-7738 Fax No.: (617) 248-7100

2582595

Attorney for Applicant Testa, Hurwitz, & Thibeault, LLP

High Street Tower 125 High Street

Boston, Massachusetts 02110